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## DESCRIPTION

#### METAL BASE CIRCUIT BOARD AND ITS PRODUCTION PROCESS

# 5 TECHNICAL FIELD

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The present invention relates to a metal base circuit board suitable for high frequency operation and its production process. Particularly, the present invention relates to a metal base circuit board suitably used for a hybrid integrated circuit having both power semiconductor and control semiconductor mounted, and its production process.

#### BACKGROUND ART

15 A metal base circuit board comprising an insulating layer made of e.g. an epoxy resin containing an inorganic filler provided on a metal plate, and having a circuit provided thereon, is excellent in heat dissipation properties and is thereby used as a circuit board on which a highly heat generating electronic component is to be mounted.

Fig. 1-1 illustrates one example of a conventional hybrid integrated circuit comprising a metal base circuit board and a semiconductor device mounted thereon. In its structure, a power semiconductor 2 and a signal conditioning semiconductor (hereinafter sometimes referred to as a control semiconductor) 1 are mounted on

circuits 3 made of e.g. copper via solder. Further, in its structure, the semiconductors are electrically connected via the copper circuit or via a bonding wire 5. When the power conductor 2 is mounted on the circuit 3, a heat sink 6 is interposed therebetween in many cases so as to accelerate heat dissipation and to prevent an increase in temperature of the power semiconductor which may lead to malfunction (Japanese Patent No. 3156798).

In the hybrid integrated circuit having the above structure, each of the semiconductors and a metal base board are electrically and electrostatically connected. Accordingly, when it is intended to increase the operating frequency (several hundred kHz or above), signals (digital signals) from the control semiconductor 1 are distorted, the power semiconductor 2 malfunctions, and the apparatus itself does not operate as designed in some cases. As a countermeasure against the above, lift-off may be employed so as to eliminate bad influences of the capacitance resulting from a metal board, but there are many problems in view of cost and assembling.

Further, Fig. 1-2 illustrates an example of another known hybrid integrated circuit. There has been an attempt to reduce bad influences of the capacitance resulting from a metal board by increasing the thickness of an insulating layer on which a control semiconductor is mounted as compared with the structure shown in Fig. 1-1. However, in preparation of such a hybrid integrated

circuit or a metal base circuit board to be used therefor, it is required to prepare insulating layer portions with different thicknesses partially, which makes the process complicated, and which enlarges the obtained hybrid integrated circuit in an upward direction. Further, there has been an attempt to achieve the above structure by laminating a resin substrate or the like having a circuit preliminarily provided thereon on a metal plate or on a metal plate having an insulating layer provided thereon (also called a metal base board) instead of the increase in thickness of the insulating layer (Japanese Patent No. 2608980), however, the above problem still remained unsolved.

With respect to a circuit board on which a hybrid integrated circuit is mounted, along with high integration of a semiconductor device, a means becomes in the mainstream that a power semiconductor device, etc. is miniaturized and further, a resistor chip, etc. in addition to various types of semiconductor devices, is mounted on the same board. As board characteristics required are different among the respective semiconductor devices and electronic components, a circuit board having characteristics partially corresponding to the respective semiconductor devices and electronic components has been required.

Accordingly, a circuit board comprising different types of insulating layers combined has been proposed, as

disclosed in JP-A-6-90071, for example. However, it costs a lot to produce such a composite insulating board since a process of its production is complicated, and further, it is not technically easy to complicatedly combine different types of insulating layers in a small area, whereby considerable miniaturization of a circuit board has been hardly achieved.

Further, in a hybrid integrated circuit employing a metal base circuit board, usually, both power semiconductor and control semiconductor to control operation of the power semiconductor are mounted on circuits of the metal base circuit board. As characteristics required for the metal base circuit board, the former is required to be excellent in thermal conductivity even if it has a slightly high capacitance, and the latter is required to have a very low capacitance even at the sacrifice of the thermal conductivity.

However, it was found that if a control semiconductor is mounted on a circuit which is designed to have a very low capacitance, concurrent heat dissipation from the control semiconductor is insufficient, and no sufficient operating time can be secured in some cases.

# 25 DISCLOSURE OF THE INVENTION

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Under these circumstances, the present invention has been made to solve the above problems of conventional

technology. It is an object of the present invention to provide a metal base circuit board which remarkably reduces malfunction time of a semiconductor which occurs when a hybrid integrated circuit is operated at a high frequency, and which is excellent in heat dissipation properties, at a low cost.

Further, it is an object of the present invention to provide a metal base circuit board which is designed that circuit board characteristics can be partially changed and accordingly on which various types of semiconductor devices, electronic components, electric components, etc. can further be mounted on the same circuit board.

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Namely, the present inventors have conducted to solve the above problems and as a result, found that a hybrid integrated circuit with which heat from a control semiconductor can be sufficiently dissipated by providing a low dielectric constant portion at least under a circuit portion electrically connected directly to the control semiconductor, which is excellent in noise characteristics and which can sufficiently cope with high frequency operation can be obtained. The present invention has been accomplished on the basis of this discovery.

Namely, the present invention provides the following.

1-1. A metal base circuit board to be use for a hybrid integrated circuit, comprising circuits provided

on a metal plate via an insulating layer (A, B), a power semiconductor mounted on the circuit and a control semiconductor to control the power semiconductor, provided on the circuit, wherein a low capacitance portion is embedded under a circuit portion (pad portion) on which the control semiconductor is mounted.

- 1-2. The metal base circuit board according to the above 1-1, wherein the low capacitance portion is made of a resin containing an inorganic filler and has a dielectric constant of from 2 to 9.
- 1-3. The metal base circuit board according to the above 1-1 or 1-2, wherein the thickness of the low capacitance portion is from 100 to 1,000  $\mu m\,.$

- 1-4. The metal base circuit board according to the
  above 1-1, 1-2 or 1-3, wherein the circuit portion (pad
  portion) on which the control semiconductor is mounted is
  provided on the low capacitance portion embedded in the
  metal plate via the insulating layer (B).
- 1-5. A process for producing a metal base circuit

  20 board, which comprises (1) a step of filling concaves of
  a metal plate having concave portions on one principal
  plane, with a substance to form a low capacitance portion
  to the same level of height as the surface of an
  insulating layer (A), to form a plate provided with a low
  25 capacitance member, (2) a step of providing an insulating
  layer (B) made of a resin containing an inorganic filler
  on the surface of the low capacitance portion and the

insulating layer (A) of the plate provided with a low capacitance member to form a board provided with a low capacitance member, (3) a step of providing a metal foil on the surface of the insulating layer (B) of the board provided with a low capacitance member to form a metal assembly, and (4) a step of processing the metal foil of the metal assembly to form circuits, including forming a circuit portion (pad portion) on which a control semiconductor is to be mounted from the metal foil located at least at the surface of the low capacitance portion.

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- 1-6. The process for producing a metal base circuit board according to the above 1-5, wherein the metal plate having concave portions on one principal plane is prepared by
- (a) a step of providing the insulating layer (A) made of a resin containing an inorganic filler on a desired position of the principal plane of the metal plate, and
- (b) a step of etching the metal plate employing the
  insulating layer (A) as a mask to form the concave
  portions on the surface of the metal plate.
  - 2-1. A metal base circuit board comprising circuits provided on a metal plate via an insulating layer, wherein a dent portion is provided on one side of the metal plate in such a state that the circumferential portion thereof is not opened, and insulating layers made of the same material are provided both on the space of

the dent portion and on the metal plate on which the dent portion is present.

- 2-2. The metal base circuit board according to the above 2-1, wherein the maximum depth of the dent portion is from 10 to 50% of the thickness of the metal plate, the size of the dent portion as viewed from the vertical direction is at least 50% of the area of the metal plate, and in a shape of the dent portion as viewed from the vertical direction, the corner has a curvature radius of at least 2.5 mm.
- 2-3. The metal base circuit board according to the above 2-1 or 2-2, wherein the insulating layers are made of a resin containing an inorganic filler, and the resin composition after cured has a storage elastic modulus of at most 15,000 MPa at 300 K.

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- 3-1. A metal base circuit board to be used for a hybrid integrated circuit, comprising a metal plate, an insulating layer provided on the metal plate, circuits provided on the insulating layer and a plurality of semiconductors mounted on the circuits, wherein a low dielectric constant portion is provided on the metal plate under a part of the circuits on which no semiconductor is mounted.
- 3-2. The metal base circuit board according to the
  above 3-1, wherein the low dielectric constant portion is
  formed by providing a dent portion on the surface of the
  metal plate and filling the dent portion with a resin

containing an inorganic filler.

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- 3-3. The metal base circuit board according to the above 3-2, wherein the side wall of the dent portion has a gradient of from 35 to 65°.
- 3-4. The metal base circuit board according to the above 3-2 or 3-3, wherein the inorganic filler is made of fused silica (silicon dioxide), and the fused silica comprises from 3.5 to 45.0 vol% of particles having an average particle size of from 0.3 to 5.0 μm and from 18.0 to 80.0 vol% of particles having an average particle size of from 6 to 30 μm.
  - 4-1. A metal base circuit board to be used for a hybrid integrated circuit, comprising a metal plate, an insulating layer provided on the metal plate, circuits provided on the insulating layer and a plurality of semiconductors mounted on the circuits, wherein dent portions are provided on the surface of the metal plate under a part of the circuits on which no semiconductor is mounted, the dent portions are filled with a resin containing an inorganic filler, and the corner portion of the dent portions as viewed from the vertical direction has a curvature radius of at least 0.4 mm.
  - 4-2. The metal base circuit board according to the above 4-1, wherein the inorganic filler is made of fused silica (silicon dioxide), and the fused silica comprises from 3.5 to 45.0 vol% of particles having an average particle size of from 0.3 to 5.0 μm and from 18.0 to 80.0

vol% of particles having an average particle size of from 6 to 30 um.

- 5-1. A process for producing a metal base circuit board to be used for a hybrid integrated circuit, comprising a metal plate, an insulating layer provided on the metal plate, circuits provided on the insulating layer, a power semiconductor mounted on the circuit and a control semiconductor to control the power semiconductor, provided on the circuit, which comprises (1) a step of forming concave portions on the principal plane at the 10 side where the insulating layer is provided on the metal plate, (2) a step of applying an insulating adhesive to the concave portions and the metal plate at a portion other than the concave portions to the same level of 15 height, (3) a step of providing a metal foil on the surface of the insulating adhesive and curing the insulating adhesive to form a metal assembly, and (4) a step of processing the metal foil of the metal assembly to form circuits.
- 5-2. A metal base circuit board obtained by the process for producing a metal base circuit board as defined in the above 5-1, wherein the insulating adhesive is made of a resin containing an inorganic filler and has a coefficient of thermal conductivity after cured of at least 1.3 W/mK.
  - 5-3. The metal base circuit board according to the above 5-2, wherein the capacitance per unit area between

the metal plate and the circuit on the concave portion filled with the insulating adhesive is at most  $50 \text{ pF/cm}^2$ , and the capacitance per unit area between the metal plate and the circuit at a portion other than the above is at least  $50 \text{ pF/cm}^2$  and at most  $160 \text{ pF/cm}^2$ .

## EFFECTS OF THE INVENTION

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- 1. In the metal base circuit board of the present invention, a low capacitance portion is embedded under a circuit portion on which a control semiconductor is mounted and under a circuit to which high frequency signals are transmitted, so as to reduce distortion of signals from the control semiconductor to a power semiconductor. Further, the low capacitance portion which is generally poor in heat dissipation properties is not formed and only an insulating layer excellent in heat dissipation properties is present under a circuit portion on which the power semiconductor is mounted.

  Accordingly, by using such a metal base circuit board, a hybrid integrated circuit which hardly malfunctions even in high frequency operation can easily be obtained.
- 2. The metal base circuit board of the present invention having the above structure is characterized in that characteristics of the circuit board can be partially changed and various types of semiconductor device, etc. can be mounted on the same circuit board, and it can be suitably used for a hybrid integrated

circuit having both power semiconductor and control semiconductor, for example. Further, in the circuit board, a heat generating electronic component and a high frequency generating apparatus can be properly disposed at desired portions. Accordingly, problems of the conventional technology can be solved, such that an insulating layer which can absorb a stress is to be designed thick so as to achieve low stress properties, but the heat resistance becomes large as the trade-off. Resultingly, such effects can also be obtained that heat cycle resistance of a mounted electronic component such as a chip resistor improves.

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3. The metal base circuit board of the present invention is a metal base circuit board to be used for a hybrid integrated circuit having a plurality of semiconductors including a control semiconductor generating a large amount of heat. By the above structure, that is, by making a low dielectric constant portion be present under a circuit which is directly connected to the control semiconductor, heat generated by the control semiconductor is immediately dissipated to a metal plate through the circuit and the insulating layer, while the operating characteristics of the control semiconductor are maintained. Accordingly, the metal base circuit board can be applied to a hybrid integrated circuit for e.g. a high frequency filter such as a macrostrip-line, a high frequency electric source and an audio

digital amplifier, to which a conventional metal base circuit board can not be applied, and industrially new applications will be broadened.

Further, the metal base circuit board of the present
invention has the above structure and in addition, has
such a structure that the low dielectric constant portion
has a specific shape, and specific fused silica (silicon
dioxide) is used as an inorganic filler, whereby the
metal base circuit board of the present invention has
more excellent dielectric characteristics, a
semiconductor device can be operated with high
reliability, and accordingly operational reliability of
the hybrid integrated circuit can be increased.

- 4. Further, it employs such a structure that when a dent portion is viewed from the upward direction, a corner portion has a curvature radius (roundness) of at least 0.4 mm, whereby concentration of a stress in the low dielectric constant portion can be avoided, the adhesive force between the low dielectric constant portion and a metal plate or an insulating layer can be increased, and heat dissipation is more accelerated.
  - 5. According to the production process of the present invention, a metal base circuit board having both portion which has a low capacitance and on which a control semiconductor is suitably mounted, and portion which has a slightly high capacitance but is excellent in thermal conductivity, and on which a power semiconductor

is suitably mounted, can be obtained with a high yield. Accordingly, a metal base circuit board to be used for a hybrid integrated circuit, comprising a metal plate, an insulating layer provided on the metal plate, a circuit provided on the insulating layer, a power semiconductor mounted on the circuit and a control semiconductor to control the power semiconductor, provided on the circuit, can be provided at a low cost.

The metal base circuit board of the present invention

10 employs an insulating adhesive having a coefficient of
thermal conductivity after cured of at least 1.3 W/mK,
whereby excellent heat dissipation properties are
secured, a semiconductor device can be operated with high
reliability, and accordingly operational reliability of a

15 hybrid integrated circuit can be increased.

Further, the metal base circuit board of the present invention has both portion having a capacitance per unit area of at most 50 pF/cm<sup>2</sup> and portion of at least 50 pF/cm<sup>2</sup> and at most 160 pF/cm<sup>2</sup>, whereby reliability of a hybrid integrated circuit can be more increased by selectively mounting a control semiconductor on the former portion.

# BRIEF DESCRIPTION OF THE DRAWINGS

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25 Fig. 1-1 illustrates one example of a hybrid integrated circuit employing a conventional metal base circuit board.

- Fig. 1-2 illustrates another example of a hybrid integrated circuit employing a conventional metal base circuit board.
- Fig. 1-3 illustrates one example of a hybrid integrated circuit employing a metal base circuit board of the present invention.
  - Fig. 1-4 illustrates one example of a hybrid integrated circuit employing another metal base circuit board of the present invention.
- 10 Fig. 1-5 illustrates one example of a process for producing a metal base circuit board of the present invention.
  - Fig. 2-1 illustrates one example of a metal base circuit board and its production process of the present invention.

- Fig. 2-2 is a drawing illustrating "as viewed from the vertical direction" in the present invention.
- Fig. 2-3 is a cross-sectional view illustrating a metal base circuit board of Comparative Example 1.
- Fig. 2-4 is a cross-sectional view illustrating a metal base circuit board of Comparative Example 2.
  - Fig. 3-1 illustrates one example of a hybrid integrated circuit employing a metal base circuit board of the present invention.
- Fig. 3-2 illustrates a dent portion provided on the hybrid integrated circuit shown in Fig. 3-1.
  - Fig. 3-3 is a plan view illustrating a dent portion

provided on the hybrid integrated circuit shown in Fig. 3-1.

Fig. 4-1 is drawings illustrating a process for producing a metal base circuit board of the present invention.

Fig. 4-2 is a drawing illustrating one example of a hybrid integrated circuit employing a metal base circuit board of the present invention.

### 10 EXPLANATION OF SYMBOLS

- 1: Control semiconductor, 2: Power semiconductor, 3: Circuit, 4: Insulating layer (A), 5: Bonding wire, 6: Heat spreader, 7: Metal plate, 8: Insulating layer (B) or resin substrate, 9: Low capacitance portion, 10:
- Insulating layer (A), 11: Concave portion, 12: Low capacitance portion, 13: Insulating layer (B), 14: Metal foil, 15: Circuit (pad portion), 21: Metal plate, 22: Dent portion, 23: Insulating layer, 24: Metal foil, 25: Etching resist, 26: Circuit (metal foil), 31: Metal
- plate, 32: Insulating layer, 33: Low dielectric constant portion, 34: Bonding wire, 35: Circuit, 36: Heat spreader, 37: Power semiconductor, 38: Control semiconductor, 41: Metal plate, 42: Concave portion (space portion), 43: Insulating adhesive (insulating
- 25 layer), 44: Metal foil, 45: Circuit, 46: Heat spreader,
  47: Power semiconductor, 48: Control semiconductor, 49:
  Bonding wire

BEST MODE FOR CARRYING OUT THE INVENTION

Now, the present invention will be explained with reference to drawings.

Fig. 1-3 is a drawing illustrating a hybrid integrated circuit employing a metal base circuit board of the present invention. The metal base circuit board of the present invention is a metal base circuit board to be used for a hybrid integrated circuit, comprising circuits provided on a metal plate via an insulating layer (A, B), a power semiconductor mounted on the 10 circuit and a control semiconductor to control the power semiconductor, mounted on the circuit, characterized in that a low capacitance portion is embedded under a circuit portion (pad portion) on which the control 15 semiconductor is mounted. Namely, the metal base circuit board of the present invention has, as shown in Fig. 1-3, such a structure that a low capacitance portion 9 is embedded under a circuit portion (also called a pad portion) on which a control semiconductor 1 is mounted and a circuit to which high frequency signals are 20 transmitted, and the vicinity thereof, whereby the capacitance at the corresponding portion of the circuit board is decreased. Accordingly, distortion of signals from the control semiconductor 1 can be reduced, whereby 25 malfunction of the power semiconductor and thus the hybrid integrated circuit can be decreased or prevented.

Further, Fig. 1-4 is a drawing illustrating a hybrid

integrated circuit employing another metal base circuit board of the present invention. It has such a structure that a concave portion is formed on a desired portion on a metal plate 7, a low capacitance portion 9 is embedded in the concave portion, and a circuit is provided thereon via an insulating layer (A) 4 and an insulating layer (B) 8.

In the present invention, as a material of the low capacitance portion 9, a substance having a low dielectric constant is appropriately selected depending 10 upon capacitance characteristics required for a hybrid integrated circuit, but a resin containing an inorganic powder, which is excellent in the adhesion with the adjacent metal plate or insulating layer, is preferred. According to studies by the present inventors, the 15 dielectric constant of the resin containing an inorganic powder is preferably from 2 to 9, at which the object of the present invention is likely to be achieved. As the inorganic powder, alumina, boron nitride, magnesia, silica, silicon nitride, aluminum nitride or the like is 20 preferably used. As the resin, an epoxy resin, a phenol resin, a polyimide resin, an engineering plastic or the like is preferably used. Further, one having a dielectric constant of from 2 to 9 can be obtained by selecting the types of the inorganic powder and the resin 25 and their blend ratio.

With respect to the shape of the low capacitance

portion 9, the dimension is not limited so long as it is larger than the circuit on which a control semiconductor is mounted and the circuit to which high frequency signals are transmitted, but the thickness is required to be determined depending upon the operating frequency, the material of the low capacitance portion, etc. According to studies by the present inventors, when the thickness is at least 100  $\mu$ m and at most 1,000  $\mu$ m, a useful hybrid integrated circuit excellent in operating characteristics can be securely prepared. The thickness exceeding 1,000  $\mu$ m is not technically problematic but increases the cost.

Further, in the metal base circuit board of the present invention, a portion under the circuit portion having no low capacitance portion and a portion under the power semiconductor are required to have high heat dissipation properties, and accordingly the insulating layer (A) is preferably formed thinly as compared with the insulating layer (B) on the low capacitance portion 9, and made of a material having high thermal conductivity, as shown in Fig. 1-3.

Further, in the present invention, both insulating layer (A) and insulating layer (B) are made of a resin containing an inorganic powder. As the inorganic powder, alumina, boron nitride, magnesia, silica, silicon nitride, aluminum nitride or the like is preferably used. As the resin, an epoxy resin, a phenol resin, a polyimide resin, an engineering plastic or the like is preferably

used. The material and the composition of the insulating layer (A) and the insulating layer (B) are not necessarily different, but as mentioned above, the material and the composition of them are selected in accordance with the balance in characteristics of a portion on which a power semiconductor is mounted and a portion on which a control semiconductor is mounted.

Further, in the present invention, it is preferred that a circuit portion (also called a pad portion) on which a control semiconductor is mounted is provided on the low capacitance portion embedded in the metal plate via the insulating layer (B). When such a structure is employed, as the insulating layer (B) covers the entire surface on the circuit side, a metal base circuit board excellent in electrical reliability will be obtained. Further, as shown in Examples described hereinafter, the metal base circuit board of the present invention can be obtained without complicated process, i.e. at a low cost.

The circuit 3 is made of any one of copper, aluminum and a clad foil comprising copper and aluminum, and it is preferably appropriately subjected to plating so that wire bonding or soldering of a component such as a semiconductor or a heat sink can easily be carried out. The material of the metal plate 7 is not particularly limited so long as it is a material excellent in thermal conductivity, and aluminum, an aluminum alloy, copper or a copper alloy, which has high thermal conductivity, is

preferably selected. The thickness of the metal plate 7 is not particularly limited, and is usually from 0.5 mm to 3.0 mm.

Fig. 2-1 (h) illustrates one example of a metal base circuit board of the present invention, and Figs. 2-1 (a) to (g) illustrate one example of its production process.

Fig. 2-1 (a) illustrates a metal plate to be used for the metal base circuit board, and is not particularly limited so long as it is made of a material excellent in thermal conductivity. Usually, aluminum, an aluminum alloy, copper or a copper alloy, which has high thermal conductivity, is preferably selected. The thickness of the metal plate is not particularly limited, and is usually from 0.5 mm to 3.0 mm.

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In order to obtain the metal base circuit board of the present invention, a dent portion is formed as illustrated in Fig. 2-1 (b). The processing method therefor may be any method, but in the present invention, the dent portion is required to be provided on one side of the metal plate in such a state that the circumferential portion of the dent portion is not opened. By employing such a structure, an effect of suppressing such a phenomenon can be obtained that the insulating layer is separated from the side portion of the substrate due to a stress resulting from heat shrinkage of the metal base plate.

Further, in the present invention, with respect to

the shape and the size of the dent portion, according to results of experimental studies by the present inventors, as described hereinafter, it is preferred that the maximum depth of the dent portion is from 10 to 50% of the thickness of the metal plate, the size of the dent portion as viewed from the vertical direction is at least 50% of the area of the metal plate, and in a shape of the dent portion as viewed from the vertical direction, the corner has a curvature radius of at least 2.5 mm. Here, "as viewed from the vertical direction" means a direction as shown in Fig. 2-2.

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If the maximum depth of the dent portion is less than 10% of the thickness of the metal plate, the effect of the present invention is indefinite in some cases, and if it exceeds 50%, the metal plate itself tends to have a reduced strength and is likely to deform. If the size of the dent portion as viewed from the vertical direction is less than 50% of the area of the metal plate, no sufficient effect of the present invention will be obtained in many cases, and the control circuit can not sufficiently drawn on the same circuit board in some cases. Further, in a shape of the dent portion as viewed from the vertical direction, if a corner having a curvature radius less than 2.5 mm is present, high frequency characteristics or heat dissipation characteristics at said corner portion may be complicated, and no expected effect will be obtained in

some cases.

Then, as shown in Fig. 2-1 (d), insulating layers made of the same material are provided both in the space in the dent portion and on the metal plate on which the dent portion is present. When the material forming the insulating layers is likely to shrink, it is possible to employ such a method that the space in the dent portion is once filled with a material forming insulating layers as shown in Fig. 2-1 (c), and after the material shrunk, an insulating layer made of the same material as the above insulating layer is provided on the entire surface of the insulating layer and the metal plate.

In the present invention, the insulating layer is required to have sufficient electrical insulating properties and further have high thermal conductivity or a low dielectric constant, and have high adhesive force with a metal, and accordingly it is usually made of a resin containing an inorganic filler as described hereinafter. Specifically, the resin containing an inorganic filler of the present invention is a curable resin composition comprising a combination of (1) a resin composed mainly of an epoxy resin, (2) a curing agent having a polyether skeleton and having a primary amine group at the terminal of its main chain and (3) an inorganic filler, and using the curable resin composition, a cured product excellent in stress relaxation properties, electrical insulating properties,

heat dissipation properties, heat resistance and moisture resistance can be provided.

As the epoxy resin, a general purpose epoxy resin such as a bisphenol F epoxy resin or a bisphenol A epoxy resin may be used. When at least one member selected from an epoxy resin having a dicyclopentadiene skeleton, an epoxy resin having a naphthalene skeleton, an epoxy resin having a biphenyl skeleton and an epoxy resin having a novolac skeleton is contained in an amount of at least 10 mass% in the total epoxy resin, balance between stress relaxation properties and moisture resistance further improves. The typical epoxy resin having a novolac skeleton may be a phenol novolac epoxy resin or a cresol novolac epoxy resin, and an epoxy resin having a dicyclopentadiene skeleton, a naphthalene skeleton or a biphenyl skeleton and a novolac skeleton in combination may also be used. Further, as the epoxy resin, an epoxy resin having the above skeleton may be used alone. Further, it is possible to blend with an epoxy resin as the main component, another resin such as a thermosetting resin such as a phenol resin or a polyimide resin or a phenoxy resin, or a polymer resin such as an acrylic rubber or an acrylonitrile-butadiene rubber. However, considering the balance of stress relaxation properties, electrical insulating properties, heat resistance and moisture resistance, the blend amount of the polymer resin is preferably at most 30 mass% to the total amount

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with the epoxy resin.

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As the curing agent, a curing agent having a polyether skeleton and having a primary amine group at the terminal of its main chain is used so as to decrease the storage elastic modulus of the resin composition after cured, and it is possible to use another curing agent in combination. When an aromatic amine curing agent is used in combination, more favorable balance of stress relaxation properties, electric insulating properties, moisture resistance, etc. will be obtained. 10 As the aromatic amine curing agent, diaminodiphenylmethane, diaminodiphenylsulfone, metaphenylenediamine or the like may be used. A curing agent such as a phenol novolac resin may further be used in combination. 15

As the inorganic filler, one having favorable electric insulating properties and further having a high coefficient of thermal conductivity is used. Such a filler may, for example, be aluminum oxide, aluminum nitride, silicon nitride, boron nitride or silica, and they may be used alone or as mixed. Among them, aluminum oxide is preferred since spherical particles with which a high filling ratio is achieved is easily available at a low cost.

25 When the above-described curable resin composition is utilized as an insulating layer, the adhesion with a conductor circuit can be more improved by blending a

silane coupling agent such as epoxy silane or amino silane with the resin composition. Further, when it is utilized as an insulating layer, the thickness is determined considering stress relaxation properties, heat dissipation properties, insulating reliability, productivity, etc., and is usually at a level of from 50 to 150 µm.

In the present invention, the resin containing an inorganic filler has a storage elastic modulus after cured of preferably at most 15,000 MPa at 300 K. If it exceeds 15,000 MPa, the stress relaxation properties may be poor in some cases. On the other hand, the lower limit is not particularly limited, but is preferably at least 100 MPa at 300 K since there is possibility that the insulating layer is deformed when a great external force is applied thereto, thus impairing insulating reliability.

Then, a metal foil is disposed on the entire surface of the insulating layer of the structure shown in Fig. 2-1 (d) and heated so that they are unified, to obtain a structure shown in Fig. 2-1 (e). The metal foil used here, which becomes a circuit after processed, is a foil of a metal excellent in conductivity, such as one of copper, aluminum, nickel, iron, tin, silver and titanium, an alloy containing two or more of such metals, or a clad foil using the above metal or alloy. The foil is prepared either by an electrolytic method or a

calendering method, and metal plating such as Ni plating, Ni-Au plating or solder plating may be applied on the foil. It is more preferred that the surface on the side to be in contact with the insulating adhesive layer of the conductor circuit is preliminarily subjected to roughening treatment e.g. by etching or plating in view of adhesion with the insulating adhesive layer.

An etching resist is applied (see Fig. 2-1 (f)) to a predetermined position on the metal foil of the structure of Fig. 2-1 (e), the metal foil is subjected to etching using a predetermined etching liquid to form circuits on the metal foil (see Fig. 2-1 (g)), and then the etching resist is separated to obtain a metal base circuit board of the present invention as shown in Fig. 2-1 (h).

The metal base circuit board of the present invention, utilizing the above characteristics in structure, has such characteristics that, for example, at the time of forming the circuits, a portion on which a control semiconductor is mounted is prepared on the circuit at a deep space portion, and a portion on which a control semiconductor is mounted is prepared on the circuit at a shallow space portion, whereby a hybrid integrated circuit having both control semiconductor and power semiconductor can be formed on one circuit board, and accordingly the metal base circuit board of the present invention is suitable as a circuit board to be used for a hybrid integrated circuit for various

applications.

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Fig. 3-1 illustrates an example of a hybrid integrated circuit employing a metal base circuit board of the present invention. The hybrid integrated circuit comprises a metal base circuit board comprising a metal plate 31, an insulating layer 32 and circuits 35, and a plurality of semiconductors i.e. a power semiconductor 37 and a control semiconductor 38 mounted on the circuits 35. When the power semiconductor 37 is connected to the circuit 35, a heat spreader 36 is interposed therebetween 10 in many cases for the purpose of accelerating heat dissipation, but the heat spreader 36 is not used in some cases. Further, the control semiconductor 38 is connected to the circuit 35 with no heat spreader interposed therebetween since the control semiconductor 15 38 does not usually generate a large quantity of heat, however, needless to say, a heat spreader may be interposed therebetween. Further, in Fig. 3-1, signals from the control semiconductor 38 are electrically connected to the power semiconductor 37 through the 20 circuit 35 and a bonding wire 34.

The present invention is characterized in that a low dielectric constant portion 33 is provided at least under a circuit which is electrically connected directly to the control semiconductor 38. By such a structure, the present invention has such characteristics that it can be applicable to a hybrid integrated circuit for such an

application that concurrent heat dissipation from the control semiconductor is insufficient, and no sufficient operating time can be secured, to which a conventional metal base circuit board can not be applied.

In the present invention, a part of the metal plate 31 is replaced with a material having a dielectric constant lower than that of the metal plate, and the material is not particularly limited. For example, a metal base circuit board wherein dent portions are provided on the surface of the metal plate 31, and the dent portions are filled with a resin containing an inorganic filler, can be obtained without any significant change of a process for producing a conventional metal base circuit board. Further, such a metal base circuit board is particularly preferred since a material excellent in connectivity with the insulating layer 2 and the metal plate 31 is likely to be selected.

With respect to the dent portion, according to studies by the present inventors, the angle  $\theta$  formed by its side wall and its bottom preferably has a gradient of from 35° to 65° as shown in Fig. 3-2. If it is less than 35°, the area of the side wall portion tends to be large, and it is required that the dent portion is sufficiently large so as to secure the capacitance. If the gradient exceeds 65°, if there is a corner between the side wall and the bottom of the dent portion, a void portion is likely to remain at the corner. In either case,

electrical characteristics of the obtained metal base circuit board are likely to be deteriorated. Further, the shape of the bottom of the dent portion is not particularly limited, but it is preferably plane, since a production method excellent in mass productivity such as a mechanical method such as pressing or cutting or a chemical method such as etching with a chemical can be applied as a method of forming dents on a metal plate.

Further, with respect to the shape of the dent portion, the dimension of the dent portion when the metal base circuit board is viewed from the upward direction is larger than the circuit on which a control semiconductor is mounted and the circuit to which high frequency signals or the like are transmitted, when the metal base circuit board is used as a hybrid integrated circuit. The thickness (depth) varies depending upon e.g. the material of the insulating adhesive forming the insulating layer, and a thickness of from 50 to 800 µm is usually sufficient. The depth of the dent portions varies with each dent portion, but the dent portions preferably have the same depth, whereby processing can be carried out all at once.

Further, in the present invention, the resin containing an inorganic filler, with which the dent portions are filled, is not particularly limited so long as it has a low dielectric constant, but preferred is one having high thermal conductivity.

The inorganic filler may, for example, be aluminum oxide, silicon oxide, aluminum nitride or boron nitride, and among them, aluminum oxide, silicon oxide or boron nitride is preferred, with which a low dielectric constant portion can be obtained with favorable balance between low dielectric constant and high coefficient of thermal conductivity. The shape of particles constituting the inorganic filler is not particularly limited, but spherical particles are preferred in view of 10 improvement in fluidity, and an inorganic filler consisting of particles having a hollow is more preferred since the dielectric constant at the low dielectric constant portion further decreases. Particularly, according to results of studies by the present inventors, 15 fused silica (silicon dioxide) comprising from 3.5 to 45.0 vol% of particles having an average particle size of from 0.3 to 5.0 µm and from 18.0 to 80.0 vol% of particles having an average particle size of from 6 to 30 µm is excellent in high filling properties and is more 20 preferred since a low dielectric constant portion having favorable balance between low dielectric constant and high coefficient of thermal conductivity can be stably and securely obtained.

As the resin, a thermosetting resin such as an epoxy
resin, a phenol resin or a polyimide resin, an
engineering plastic, a thermoplastic resin such as a
polyethylene, a polypropylene, vinylidene chloride, a

polyethylene terephthalate, an ABS resin or an AS resin, or an acrylic resin, a silicone resin or a urethane resin may, for example, be used. Among them, it is preferred to use the same resin as for the insulating layer, and an epoxy resin is preferably used, which has favorable adhesion with the metal plate.

In the present invention, the material of the metal plate is not particularly limited so long as it is excellent in thermal conductivity, and aluminum, an aluminum alloy, copper or a copper alloy, which has high thermal conductivity, is preferably selected. The thickness of the metal plate is not particularly limited and is usually from 0.3 mm to 4.0 mm.

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In the present invention, the composition and characteristics of the insulating layer are also very 15 important. The insulating layer is formed by a resin containing an inorganic filler. As the inorganic filler, an electrically insulating inorganic compound such as alumina (aluminum oxide), boron nitride, magnesia (magnesium oxide), barium sulfate, zinc oxide, silica 20 (silicon dioxide), silicon nitride or aluminum nitride is used, and alumina, boron nitride, aluminum nitride or silica which is easily available at a low cost, is preferably used. Among them, alumina or aluminum nitride is more preferably selected, since their particles are 25 spherical and a high filling ratio can be achieved, and an insulating layer having extremely high thermal

conductivity can easily be obtained.

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As the resin, a thermosetting resin such as an epoxy resin, a phenol resin or a polyimide resin, an engineering plastic, a thermoplastic resin such as a polyethylene, a polypropylene, vinylidene chloride, a polyethylene terephthalate, an ABS resin or an AS resin, or an acrylic resin, a silicone resin, a urethane resin or a fluororesin may, for example, be used, and particularly, an epoxy resin which is excellent in connectability with the metal plate is preferably selected.

Namely, in the present invention, as the combination of the inorganic filler and the resin, an epoxy resin containing one or more of alumina, boron nitride,

aluminum nitride and silica is a preferred combination since it has high adhesive force with the metal plate or a metal foil forming a circuit, and an insulating layer having a high coefficient of thermal conductivity or having a low capacitance after cured can easily be obtained. Further, the same applies to a resin containing an inorganic filler constituting the above low dielectric constant portion.

As a method of applying the resin containing an inorganic filler in an uncured state (hereinafter sometimes referred to simply as insulating adhesive) to a predetermined portion, generally, a roll coater, a gravure coater, a kiss roll coater or screen printing

may, for example, be employed. Further, the insulating adhesive is formed in a single layer or in plural layers. When it is formed in plural layers, the process becomes long, thus increasing the cost, but dielectric breakdown resistance improves and further, the accuracy of thickness of the insulating layer improves.

In the present invention, as a material of the circuit and a metal foil forming it, any one of copper, aluminum, nickel, iron, tin, silver and titanium, an alloy containing two or more of such metals, or a clad foil using the above metal or alloy, may, for example, be used. Further, the metal foil may be prepared either by an electrolytic method or a calendering method, and metal plating such as Ni plating, Ni-Au plating or solder plating may be applied on the metal foil. It is more preferred that the surface on the side to be in contact with the insulating adhesive of the metal foil (circuit) is preliminarily subjected to roughening treatment e.g. by etching or plating in view of adhesion with the insulating adhesive.

Some of the circuits of the metal base circuit board of the present invention are on the metal plate via an insulating layer, and the others are on the metal plate via an insulating layer and a low dielectric constant portion. In production of a hybrid integrated circuit employing the metal base circuit board of the present invention, by mounting control electronic components such

as a resistor chip and a condenser chip on the latter circuits, distortion of signals from the control semiconductor can be reduced, and by mounting a power semiconductor, a control semiconductor, etc. on the former circuits, excessive increase in temperature of the semiconductors and the resulting malfunction can be prevented. As a result, such an effect that highly reliable operation can be secured as the whole hybrid integrated circuit, can be obtained.

In the embodiment of the present invention, regarding the above dent portion, the corner portion as viewed from the upward direction has a curvature radius (roundness) of at least 0.4 mm as shown in Fig. 3-3. With respect to the shape of the dent portion, the dent portion is formed along the shape of a circuit mounted on the low dielectric constant portion, since the thermal conductivity at the low dielectric constant portion is lower than that of the metal plate. As its shape, usually a square or a rectangle is employed in many cases, but a polygon such as a triangle, a pentagon or a hexagon or a round shape such as a circle or an ellipse may be employed in some cases.

The present inventors have conducted experimental studies on the shape of the dent portion and as a result, found that when the corner portion has a curvature radius of at least 0.4 mm, no void will remain at the corner of the dent, whereby a metal base circuit board having

predetermined characteristics can be stably obtained, and accomplished the present invention. The present invention is characterized in that the smallest corner portion has a curvature radius (roundness) of at least 0.4 mm, regardless of the shape of the dent portion as viewed from the upward direction, i.e. a polygon or a round shape.

Further, with respect to the shape of the dent portion, the dent portion should be larger than the circuit on which a control semiconductor is mounted and a circuit to which high frequency signals or the like are transmitted, when the metal base circuit board is viewed from the upward direction. The thickness (depth) varies depending upon e.g. the material of the insulating adhesive forming an insulating layer, and is usually from 50 to 800  $\mu m$ .

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The concave-convex shape of the dent portions is not particularly limited, but the bottoms are preferably plane, i.e. the dent portions have the same depth, whereby a production method excellent in mass productivity such as a mechanical method such as pressing or cutting or a chemical method such as etching with a chemical can be applied as a method of forming dents on the metal plate.

25 Fig. 4-1 is drawings illustrating a process for producing a metal base circuit board of the present invention. First, concave portions are formed on desired

portions on the surface of a metal plate (see Fig. 4-1 (1)). As a method of forming the concave portions, a conventional method such as pressing, cutting or etching with a chemical may be mentioned. The metal plate used is not particularly limited so long as it is made of a material excellent in thermal conductivity, and aluminum, an aluminum alloy, copper or a copper alloy, which has high thermal conductivity, is preferably selected. Further, the thickness of the metal plate is not particularly limited and is usually from 0.3 mm to 4.0 mm.

With respect to the shape of the concave portion of the metal plate, the dimension of the concave portion when the metal base circuit board is viewed from the upward direction should be larger than a circuit on which a control semiconductor is mounted and a circuit to which high frequency signals or the like are transmitted, when the metal base circuit board is used as a hybrid integrated circuit. Further, although the thickness (depth) varies depending upon e.g. the material of an insulating adhesive forming an insulating layer, it is usually from 50 to 500 µm. Further, the depth of the concave portion may vary with each concave portion, but all the concave portions preferably have the same depth, whereby processing can be carried out all at once.

Then, an insulating adhesive is applied to the above concave portions and the metal plate other than the

concave portions to the same level of height (see Fig. 4-1 (2)). As a method of applying the insulating adhesive, usually a roll coater, a gravure coater, a kiss roll coater or screen printing may, for example, be employed.

Further, the insulating adhesive is formed in a single layer or plural layers. In a case where the insulating adhesive is formed in plural layers, the process becomes long, thus increasing the cost, but dielectric breakdown resistance improves and further, the accuracy of thickness of the insulating layer improves.

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Then, a metal foil is provided on the surface of the insulating adhesive to form a metal assembly (see Fig. 4-1 (3)), and then the metal foil of the metal assembly is processed to form circuits (see Fig. 4-1 (4)). As a material of the metal foil used in the present invention and the circuits formed from the metal foil, any one of copper, aluminum, nickel, iron, tin, silver and titanium, an alloy containing two or more of such metals or a clad foil using the above metal or alloy may, for example, be used. The metal foil may be prepared either by an electrolytic method or a calendering method. Metal plating such as Ni plating, Ni-Au plating or solder plating may be applied on the metal foil. It is more preferred that the surface on the side to be in contact with the insulating adhesive of the metal foil (circuit) is preliminarily subjected to roughening treatment e.g. by etching or plating, in view of adhesion with the

insulating adhesive.

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Fig. 4-2 is a drawing illustrating one example of a hybrid integrated circuit employing a metal base circuit board obtained by the process for producing a metal base circuit board of the present invention. As shown in Fig. 4-2, on the metal base circuit board of the present invention, at least two types of circuits i.e. circuits provided on portions where the insulating layer is locally thick (corresponding to the concave portions provided on the metal plate) and circuits provided on 10 portions where the insulating layer is not locally thick (corresponding to portions other than the concave portions of the metal plate) are provided. By mounting control electronic components such as a resistor chip and 15 a condenser chip on the former circuits, distortion of signals from a control semiconductor can be reduced, and by mounting a power semiconductor, a control semiconductor, etc. on the latter circuits, excessive increase in temperature of the semiconductors and the resulting malfunction can be prevented, whereby highly 20 reliable operation can be secured as the whole hybrid integrated circuit.

In the present invention, the composition and characteristics of the insulating adhesive are very important. In the present invention, the insulating adhesive is made of a resin containing an inorganic filler. As the inorganic filler, an inorganic substance

such as alumina (aluminum oxide), boron nitride, magnesia (magnesium oxide), barium sulfate, zinc oxide, silica (silicon dioxide), silicon nitride or aluminum nitride is preferably used. As the resin, a thermosetting resin such as an epoxy resin, a phenol resin or a polyimide resin, an engineering plastic, a thermoplastic resin such as a polyethylene, a polypropylene, vinylidene chloride, a polyethylene terephthalate, an ABS resin or an AS resin, or an acrylic resin, a silicone resin or a urethane resin may, for example, be preferably used.

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As the combination of the inorganic filler and the resin, an epoxy resin containing one or more of alumina, boron nitride, aluminum nitride and silica is more preferred, which has high adhesion with the metal plate or the metal foil, and with which an insulating layer having a high coefficient of thermal conductivity or an insulating layer having a low capacitance after cured can easily be obtained.

In the present invention, the insulating adhesive

10 has a coefficient of thermal conductivity after cured of

preferably at least 1.3 W/mK. When an insulating

adhesive having a high coefficient of thermal

conductivity is used, a hybrid integrated circuit having

higher reliability can be obtained, and it can be used as

25 a hybrid integrated circuit to be used for vehicles such

as automobiles and trains, for example.

Further, in the present invention, it is preferred

that the capacitance per unit area between the metal plate and the circuit in the concave portion filled with the insulating adhesive is at most 50 pF/cm², and the capacitance per unit area between the metal plate and the circuit at a portion other than the concave portion is at least 50 pF/cm² and at most 160 pF/cm², whereby more remarkable effects of the present invention will be obtained, and a practical hybrid integrated circuit to be used for vehicles such as automobiles and trains, for example, can be provided.

Now, the metal base circuit board and its production process of the present invention will be explained in detail below with reference to Examples.

# EXAMPLE 1-1

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As shown in Fig. 1-5 (1), an insulating layer (A) 10 with a thickness of 20 μm made of an epoxy resin containing 60 vol% of alumina was provided on a desired position on an aluminum plate of 50 mm × 50 mm × (thickness mm), and the metal plate 7 was subjected to etching employing the insulating layer (A) as a mask to form concave portions 11 with a depth of 300 μm on the surface of the metal plate (Fig. 1-5 (2)).

The concave portions 11 on the metal plate 7 were filled with an epoxy resin containing 60 vol% of silica to the same level of height as the surface of the insulating layer (A) 10 to form low capacitance portions 12 (Fig. 1-5 (3)).

Then, an insulating layer (B) 13 made of an epoxy resin containing 60 vol% of alumina was formed in a thickness of 30  $\mu$ m (Fig. 1-5 (4)), and further, a metal foil 14 was laminated to obtain a metal base board (Fig. 1-5 (5)).

Using the metal base board, a circuit (pad portion) on which a control semiconductor is mounted and another desired circuit 3 were formed from the metal foil located on the low capacitance portion to prepare a metal base circuit board to be used for a hybrid integrated circuit containing a power semiconductor and a control semiconductor to control the power semiconductor.

Using the metal base circuit board, a digital amplifier (hybrid integrated circuit) wherein a digital signal IC as a control semiconductor and MOS-FET as a power semiconductor were mounted on the circuits was experimentally produced and operated at an operating frequency of 600 kHz and as a result, normal operation was confirmed.

# 20 EXAMPLE 1-2

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In the same manner as in Example 1-1 except that a metal plate having concave portions on one principal plane was preliminarily prepared by etching, and an insulating layer (A) was provided on the surface of the metal plate to prepare a metal plate having a structure shown in Fig. 1-5 (2), a metal base circuit board was prepared, and a digital amplifier was prepared and

operated and as a result, it was confirmed that it normally operated continuously for at least 1 hour at an operating frequency of 600 kHz.

# COMPARATIVE EXAMPLE 1-1

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An aluminum plate was coated with an epoxy resin containing 60 vol% of alumina in a thickness of 50 µm, and a copper foil was laminated thereon to prepare a metal base board. Using the metal base board, the same operation as in Example 1-1 was carried out to prepare a metal base circuit board, and a digital amplifier was prepared and operated and as a result, it malfunctioned. The operating frequency was 600 kHz, which was the same as in Example 1-1.

# COMPARATIVE EXAMPLE 1-2

An epoxy resin containing 60 vol% of silica was formed in a thickness of 300 µm on an aluminum plate, and a copper foil was laminated to prepare a metal base board. Using the metal base board, the same operation as in Example 1-1 was carried out to prepare a metal base circuit board, and a digital amplifier was prepared and operated. As a result, it normally operated at the beginning of operation at an operating frequency of 600 kHz, but it stopped operating after operation for five seconds due to heat generation of a power transistor. EXAMPLES 2-1 TO 2-4 AND COMPARATIVE EXAMPLES 2-1 AND 2-2

A thermosetting resist ink was applied to a desired position on an aluminum plate of 50 mm  $\times$  50 mm  $\times$  2 mm,

and a dent portion with a size and a depth as shown in Table 1 was formed by alkali etching, and then the resist ink was removed.

Then, 100 parts by mass of a bisphenol F epoxy resin (Epikote 807: epoxy equivalent = 173, manufactured by Japan Epoxy Resins Co., Ltd.) as an epoxy resin, 5 parts by mass of γ-glycidoxypropylmethyldiethoxysilane (AZ-6165: manufactured by Nippon Unicar Company Limited) as a silane coupling agent and 500 parts by mass of alumina (AS-50: manufactured by SHOWA DENKO K.K.) having an average particle size of 5 μm as an inorganic filler were mixed by a universal mixer.

To the above mixture, 25 parts by mass of a polyoxypropyleneamine (JEFFAMINE T-403: manufactured by Texaco Chemical Company) and 20 parts by mass of a polyoxypropylene amine (JEFFAMINE D2000, manufactured by Texaco Chemical Company) were blended and mixed to obtain a resin, and the above-described dent portion was filled with an insulating material made of the above prepared resin in a thickness of 20 µm, and further, an insulating layer was formed in a thickness of 30 µm. Further, a copper foil was laminated to obtain a metal base board. Further, with respect to the metal base board, the copper foil was subjected to etching with a ferric chloride solution to form circuits having pad portions on which a chip resistor can be mounted, whereby a metal base circuit board was obtained.

The metal base circuit board was subjected to a heat cycle test described hereinafter, and the results are shown in Table 2-1.

# HEAT CYCLE TEST METHOD

A chip resistor with a size of 2.0 mm × 1.25 mm is soldered between the pads, and a test is carried out with one cycle being from -40°C for seven minutes to +125°C for seven minutes, and presence or absence of cracks at the soldered portion is observed by a microscope. The number of cycles when occurrence of cracks at the soldered portion becomes 50% or higher is taken as the index of heat cycle resistance.

TABLE 2-1	2-1							•	
				Dent	Dent portion		•		· da
	NO.	Opening to the circumference	Proportion to the whole area of the metal plate (%)	Maximum depth (µm)	Number	Minimum shape (mm)	Maximum Shape (mm)	Agreement with a portion on which a chip resistor is mounted	Heat cycle resistance (cycles)
	2-1	Ni1	81.0	800	1	45 × 45 portic	45 × 45 (corner portion: 3R)	Present	3,000
	2-2	Nil	64.3	400	2	32 in c	32 in diameter	Present	2,500
EX.	2-3	Lin	59.7	400	4	10 in diameter	40 in diameter	Present	2,500
	2-4	Nil	62.8	300	5	20 in c	20 in diameter	Present	2,500
Comp.	2-1	Present	81.0	800	1	45 × 45 portic	45 × 45 (corner portion: 3R)	Present	Insulating layer cracked
	2-2	Nil	0.0	1	ı		_	Nil	1,000

# EXAMPLE 3-1

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A thermosetting resist ink was applied to a desired position on an aluminum plate of 150 mm  $\times$  150 mm  $\times$  1.5 mm, and dents with a depth of 300  $\mu$ m and a gradient at the side wall of 43° were formed by etching, and then the resist ink was removed.

Then, alumina (LS-20, manufactured by Nippon Light Metal Company, Ltd.) having an average particle size of 2 µm was blended in an amount of 45 vol% with a bisphenol A liquid epoxy resin (EP828, manufactured by Japan Epoxy Resins Co., Ltd.) and mixed to prepare an insulating adhesive A.

Further, fused spherical silica (FB-1SDX, manufactured by Denki Kagaku Kogyo Kabushiki Kaisha) having an average particle size of 1.7 µm in an mount of 37 vol% and fused spherical silica (FB-550, manufactured by Denki Kagaku Kogyo Kabushiki Kaisha) having an average particle size of 11.3 in an amount of 40 vol% were blended with a bisphenol A liquid epoxy resin (EP828, manufactured by Japan Epoxy Resins Co., Ltd.) and mixed to prepare an insulating adhesive B.

The insulating adhesive B was applied to the aluminum plate having the dent portions, and then the insulating adhesive A was applied so that the thickness of the insulating layer at a portion other than the dent portions would be 50  $\mu$ m. Further, a copper foil was laminated on the insulating adhesive A to obtain a metal

base board.

With respect to the metal base board, the copper foil was subjected to etching with a desired position masked with an etching resist, and then the etching resist was removed, followed by washing and drying to form circuits, whereby a metal base circuit board was obtained. For formation of the circuits, circuits on which a resistor chip or a condenser which was to be electrically connected directly from a control semiconductor were formed on the dent portions, and circuits on which a power semiconductor or a control semiconductor was to be mounted were formed on a portion other than the dent portions.

With respect to the metal base circuit board obtained by the above operation, the dielectric breakdown voltage and the capacitance per unit area were measured. The dielectric breakdown voltage was measured in accordance with JIS C2110. Further, the capacitance per unit area was obtained in such a manner that the capacitance at a measurement frequency of 1 MHz was obtained by an LCR meter, and the area of the portion which was in contact with the insulating adhesive of a circuit at the measured portion was obtained, and the capacitance was divided by the area of the circuit. Principal preparation conditions of the metal base circuit board and the measurement results are shown in Table 3-1.

TABLE 3-1

		Ex.	Comp. Ex.
Dent portion	Dielectric breakdown voltage (kV)	6.4	
	Capacitance (pF/cm²)	10	
Other portion	Dielectric breakdown voltage (kV)	4.2	3.6
	Capacitance (pF/cm²)	130	128
Operation of hybrid integrated circuit		0	×

Then, using the metal base circuit board, a hybrid integrated circuit as shown in Fig. 3-1 was prepared.

5 The hybrid integrated circuit is a digital amplifier having a digital signal IC as a control semiconductor and MOS-FET as a power semiconductor mounted. The hybrid integrated circuit was operated at an operating frequency of 1.2 MHz and as a result, normal operation was confirmed.

# COMPARATIVE EXAMPLE 3-1

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The same operation as in Example 3-1 was carried out except that a flat aluminum plate with no dents was used, and that the insulating adhesive A was applied in a thickness of 50 µm on the aluminum plate, a metal base board was prepared, and then a metal base circuit board was prepared. The results of measurement of the metal base circuit board are shown in Table 3-1. Further, in the same manner as in Example 3-1, a digital amplifier was prepared and operated and as a result, it malfunctioned.

# EXAMPLE 4-1

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A thermosetting resist ink was applied to a desired position on an aluminum plate of 150 mm  $\times$  150 mm  $\times$  1.5 mm, and dent portions which were rectangular as viewed from the upward direction and the corner portions of which had a roundness (R) of at least 0.6 R were formed with a depth of 300  $\mu$ m by etching, and then the resist ink was removed.

Then, alumina (LS-20, manufactured by Nippon Light Metal Company, Ltd.) having an average particle size of 2 µm was blended in an amount of 45 vol% with a bisphenol A liquid epoxy resin (EP828, manufactured by Japan Epoxy Resins Co., Ltd.) and mixed to prepare an insulating adhesive A.

Further, fused spherical silica (FB-1SDX, manufactured by Denki Kagaku Kogyo Kabushiki Kaisha) having an average particle size of 1.7 µm in an mount of 37 vol% and fused spherical silica (FB-550, manufactured by Denki Kagaku Kogyo Kabushiki Kaisha) having an average particle size of 11.3 in an amount of 40 vol% were blended with a bisphenol A liquid epoxy resin (EP828, manufactured by Japan Epoxy Resins Co., Ltd.) and mixed to prepare an insulating adhesive B.

The insulating adhesive B was applied to the

25 aluminum plate having the dent portions, and then the

insulating adhesive A was applied so that the thickness

of the insulating layer at a portion other than the dent

portions would be 50  $\mu m$ . Further, a copper foil was laminated on the insulating adhesive A to obtain a metal base board.

With respect to the metal base board, the copper foil was subjected to etching with a desired position masked with an etching resist, and then the etching resist was removed, followed by washing and drying to form circuits, whereby a metal base circuit board was obtained. For formation of the circuits, circuits on which a resistor chip or a condenser which was to be electrically connected directly from a control semiconductor were formed on the dent portions, and circuits on which a power semiconductor or a control semiconductor was to be mounted were formed on a portion other than the dent portions.

With respect to the metal base circuit board obtained by the above operation, the dielectric breakdown voltage and the capacitance per unit area were measured. The dielectric breakdown voltage was measured in accordance with JIS C2110. Further, the capacitance per unit area was obtained in such a manner that the capacitance at a measurement frequency of 1 MHz was obtained by an LCR meter, and the area of the portion which was in contact with the insulating adhesive of a circuit at the measured portion was obtained, and the capacitance was divided by the area of the circuit. The metal base circuit board obtained in the present Example had the same

characteristics as in Example 3-1.

Then, using the metal base circuit board, a hybrid integrated circuit as shown in Fig. 3-1 was prepared. The hybrid integrated circuit is a digital amplifier having a digital signal IC as a control semiconductor and MOS-FET as a power semiconductor mounted. The hybrid integrated circuit was operated at an operating frequency of 1.2 MHz and as a result, normal operation was confirmed.

# 10 EXAMPLE 5-1

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A thermosetting resist ink was applied to a desired position on an aluminum plate of 150 mm  $\times$  150 mm  $\times$  1.5 mm, and concave portions with a depth of 200  $\mu$ m were formed by etching, and then the resist ink was removed.

Then, alumina (LS-20, manufactured by Nippon Light Metal Company, Ltd.) having an average particle size of 2 µm was blended in an amount of 45 vol% with a bisphenol A liquid epoxy resin (EP828, manufactured by Japan Epoxy Resins Co., Ltd.) and mixed to prepare an insulating adhesive.

The insulating adhesive was applied to the aluminum plate having the concave portions so that the concave portions were filled with the insulating adhesive and that the thickness of an insulating layer at a portion other than the concave portions would be 60 µm. Further, a metal foil was laminated on the insulating adhesive to obtain a metal base board. With respect to the

insulating adhesive, it was cured into a shape with a diameter of 10 mm and a thickness of 2 mm to prepare a test specimen for measuring the coefficient of thermal conductivity and evaluation was carried out and as a result, it was 1.5 W/mK.

Further, the capacitance per unit area between the metal plate and a circuit on the concave portion filled with the insulating adhesive was 35 pF/cm², and the capacitance per unit area between the metal plate and a circuit at a portion other than the concave portions was 120 pF/cm². The capacitance per unit area was obtained in such a manner that the capacitance at a measurement frequency of 1 Mz was obtained by an LCR meter, the area of a portion which was in contact with the insulating adhesive of a circuit at the measured portion was obtained, and the capacitance was divided by the area of the circuit.

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Then, a hybrid integrated circuit having a control semiconductor to control a power semiconductor was formed on the concave portion of the metal base board, and a circuit having a power semiconductor or a control semiconductor was formed at a portion other than the concave portions, to obtain a metal base circuit board.

Then, using the metal base circuit board, a hybrid integrated circuit as shown in Fig. 4-2 was prepared.

The hybrid integrated circuit is a digital amplifier having a digital signal IC as a control semiconductor and

MOS-FET as a power semiconductor mounted. The hybrid integrated circuit was operated at an operating frequency of 600 kHz and as a result, normal operation was confirmed.

# 5 EXAMPLE 5-2

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In the same manner as in Example 5-1 except that an epoxy resin containing 60 vol% of an aluminum filler was used as the insulating adhesive, a cured test specimen of the insulating adhesive, a metal base board and a metal base circuit board were prepared. The coefficient of thermal conductivity of the insulating adhesive was 2.8 W/mK, the capacitance per unit area between the metal plate and a circuit at the concave portion filled with the insulating adhesive was 45 pF/cm², and the capacitance per unit area between the metal plate and a circuit at the portion other than the concave portions was 140 pF/cm².

A digital amplifier was prepared in the same manner as in Example 5-1 and operated and as a result, it was confirmed that it normally operated continuously for at least 1 hour at an operating frequency of 600 kHz.

COMPARATIVE EXAMPLE 5-1

In the same manner as in Example 5-1 except that a flat aluminum plate with no concaves was used and that the insulating adhesive was applied in a thickness of 60 µm on the aluminum plate, a cured test specimen of the insulating adhesive, a metal base board and a metal base

circuit board were prepared. The coefficient of thermal conductivity of the cured insulating adhesive was 1.5 W/mK, and the capacitance per unit area between a circuit and the metal plate was 123 pF/cm<sup>2</sup>.

Further, a digital amplifier was prepared in the same manner as in Example 5-1 and operated. As a result, it was operated at an operating frequency of 600 kHz but malfunctioned.

# COMPARATIVE EXAMPLE 5-2

In the same manner as in Example 5-1 except that a flat aluminum plate with no concaves was used and that the insulating adhesive was applied in a thickness of 260 µm on the aluminum plate, a cured test specimen of the insulating adhesive, a metal base board and a metal base circuit board were prepared. The coefficient of thermal conductivity of the cured insulating adhesive was 1.5 W/mK, and the capacitance per unit area between a circuit and the metal plate was 32 pF/cm<sup>2</sup>.

Further, a digital amplifier was prepared in the same manner as in Example 5-1 and operated. As a result, it normally operated at the beginning of the operation at an operating frequency of 600 kHz, but it stopped operating after operation for fire seconds due to heat generation of a power transistor.

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# INDUSTRIAL APPLICABILITY

The process for producing a metal base circuit board

of the present invention is characterized in that it can securely and stably provide a metal base circuit board having the above characteristics, and the process is industrially very useful.

The metal base circuit board of the present 5 invention is characterized in that characteristics of a circuit board varies partially even on the same circuit board, and various types of semiconductor devices, etc. can be mounted on it. For example, it can suitably be used for e.g. a hybrid integrated circuit having both 10 power semiconductor and control semiconductor. Further, a heat generating electronic component or a high frequency generating apparatus can be appropriately disposed on a desired position of the circuit board. Resultingly, such effects can also be obtained that the 15 heat cycle resistance of a mounted electronic component such as a chip resistor improves. Therefore, it is useful as a circuit board for various hybrid integrated circuits.

The metal base circuit board of the present invention has both circuit portion which has a low capacitance and on which an electronic component such as a resistor chip or a condenser to control a power semiconductor is suitably mounted and circuit portion which has a slightly high capacitance but is excellent in thermal conductivity, and on which a control semiconductor or a power semiconductor which requires

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heat dissipation is suitably mounted, and it can provide a hybrid integrated circuit with high operational reliability and is industrially very useful.

According to the production process of the present
invention, a metal base circuit board having both portion
which has a low capacitance and on which an electronic
component such as a resistor chip or a condenser to
control a power semiconductor is suitably mounted and
portion which has a slightly high capacitance but is
excellent in thermal conductivity, and on which a control
semiconductor or a power semiconductor which requires
heat dissipation is suitably mounted, is obtained at a
high yield. Accordingly, it can provide a metal base
circuit board to be used for a hybrid integrated circuit
at a low cost, and is industrially very useful.

The entire disclosures of Japanese Patent
Application No. 2003-110377 filed on April 15, 2003,
Japanese Patent Application No. 2003-275979 filed on July
17, 2003, Japanese Patent Application No. 2003-326256
20 filed on September 18, 2003, Japanese Patent Application
No. 2004-042993 filed on February 19, 2004 and Japanese
Patent Application No. 2004-055890 filed on March 1, 2004
including specifications, claims, drawings and summaries
are incorporated herein by reference in their entireties.